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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): T. USUI, et al

Serial No.: 09/788,629

Filed: February 16, 2001

For: PROCESS MONITORING METHODS IN A PLASMA
PROCESSING APPARATUS, MONITORING UNITS, AND A
SAMPLE PROCESSING METHOD USING THE MONITORING
UNITS

Group: 2812

Examiner:

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PRELIMINARY AMENDMENT

Commissioner for Patents
Washington, D.C. 20231

August 14, 2001

Sir:

The following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application.

IN THE SPECIFICATION:

Please replace the original specification with the attached Substitute Specification.

IN THE CLAIMS:

Please amend claims 6-14 as follows:

6. (amended) A potential difference and current measuring method as set forth in Claim 1, 2 or 5, wherein said potential difference and current measuring method is

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